



## UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Addrew COMMISSIONER FOR PATENTS PO Box 1450 Alexandra, Virgunia 22313-1450 www.usptc.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO	
09/759,899	01/12/2001	I. T. Chen	JCTWP020A	2833	
7:	590 08/12/2003				
J C Patents Incorporated			EXAMINER		
4 Venture Suite Irvine, CA 920			AHMED, S	AHMED, SHAMIM	
			ART UNIT	PAPER NUMBER	
			1765		
			DATE MAILED: 08/12/2003		

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)	,
Advisory Action	09/759,899	CHEN ET AL.	
Advisory Action	Examiner	Art Unit	
	Shamim Ahmed	1765	
The MAILING DATE of this communication appe	ars on the cover sheet with the c	orrespondence add	lress
THE REPLY FILED 06 August 2003 FAILS TO PLACE T Therefore, further action by the applicant is required to ave final rejection under 37 CFR 1.113 may only be either: (1) condition for allowance; (2) a timely filed Notice of Appeal Examination (RCE) in compliance with 37 CFR 1.114.	oid abandonment of this applica a timely filed amendment which	ation. A proper repl n places the applica	y to a ation in
PERIOD FOR RE	PLY [check either a) or b)]		
a) The period for reply expires 3 months from the mailing date	•		
b) The period for reply expires on: (1) the mailing date of this A no event, however, will the statutory period for reply expire I ONLY CHECK THIS BOX WHEN THE FIRST REPLY WAS 706.07(f).	ater than SIX MONTHS from the mailing FILED WITHIN TWO MONTHS OF TH	g date of the final rejecti HE FINAL REJECTION.	ion. See MPEP
Extensions of time may be obtained under 37 CFR 1.136(a). The fee have been filed is the date for purposes of determining the period of fee under 37 CFR 1.17(a) is calculated from: (1) the expiration date of (2) as set forth in (b) above, if checked. Any reply received by the Offic timely filed, may reduce any earned patent term adjustment. See 37 C	of extension and the corresponding amo the shortened statutory period for reply the later than three months after the mail	unt of the fee. The app originally set in the final	ropriate extension Office action; or
1. A Notice of Appeal was filed on Appellant's 37 CFR 1.192(a), or any extension thereof (37 CFF			
2. The proposed amendment(s) will not be entered be	ecause:		
(a) they raise new issues that would require further	er consideration and/or search (s	see NOTE below);	
(b)  they raise the issue of new matter (see Note b	elow);		
<ul><li>(c)  they are not deemed to place the application in issues for appeal; and/or</li></ul>	n better form for appeal by mate	rially reducing or si	mplifying the
(d) they present additional claims without canceli	ng a corresponding number of fi	nally rejected claim	IS.
NOTE: See Continuation Sheet.			
3. Applicant's reply has overcome the following reject	ion(s):		
4. Newly proposed or amended claim(s) would canceling the non-allowable claim(s).	be allowable if submitted in a se	eparate, timely filed	amendment
5. The a) affidavit, b) exhibit, or c) request for application in condition for allowance because:		dered but does NO	T place the
6. The affidavit or exhibit will NOT be considered becaraised by the Examiner in the final rejection.	ause it is not directed SOLELY t	o issues which were	e newly
7. For purposes of Appeal, the proposed amendment explanation of how the new or amended claims we			and an
The status of the claim(s) is (or will be) as follows:			
Claim(s) allowed:			
Claim(s) objected to:			
Claim(s) rejected: <u>5 and 6</u> .			
Claim(s) withdrawn from consideration:			
8. The proposed drawing correction filed on is	a)☐ approved or b)☐ disapp	roved by the Exami	iner.
9. Note the attached Information Disclosure Statemer	nt(s)( PTO-1449) Paper No(s).		
10. Other:	, , , , ,		
<del></del>			
	N 20	ADINE G. NORTON	_
		1.7	



Continuation of 2. NOTE: The amendment to claim 5, includes a limitation of "an overetch process using an inert gas plasma" raises a new issue, which requires further consideration.

Applicants argue that Zhao fails to teach the limitation of "an overetch process using an inert gas plasma to remove a remaining of the photoresist layer and to treat the silicon oxide material".

In response to applicant's argument, examiner states that the argument is based on the amended claim, which is not entered.

Applicants also argue that Zhao fails to teach the removal of the photoresist is divided inoto two steps.

In response, examiner states that Zhao teaches that the initial removal of the photoresist using wet/dry etching process remains undesirable residues, which can be plasma cleaned by using argon ion bombardment (see the rejection).

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Shamim Ahmed whose telephone number is (703) 305-1929. The examiner can normally be reached on M-Thu (7:00-5:30) Every Friday Off. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine G Norton can be reached on (703) 305-2667. The fax phone numbers for the organization where this application or proceeding is assigned are (703)-872-9310 for regular communications and (703) 872-9311 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0661.

Shamim Ahmed Patent Examiner Art Unit 1765

SA August 7, 2003

> NADINE G. MOHTON PRIMARY COMMERCAN